

L Number	Hits	Search Text	DB	Time stamp
6	892	SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOA-T AOA-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/27 13:01
7	101	(SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA AOA-T AOAI-TOSHIAKI AOA-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F) and lactone	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/27 13:01
8	38	(US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$ or US-6548220-\$ or US-5695906-\$ or US-6461788-\$).did. or (US-20020009666-\$ or US-20020132181-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$ or US-20010044070-\$ or US-20030059715-\$).did. or (JP-2001240625-\$ or JP-2001188346-\$ or JP-2001142213-\$).did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/27 13:02
9	99	((SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA AOA-T AOAI-TOSHIAKI AOA-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F) and lactone ) not ((US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$ or US-6548220-\$ or US-5695906-\$ or US-6461788-\$).did. or (US-20020009666-\$ or US-20020132181-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$ or US-20010044070-\$ or US-20030059715-\$).did. or (JP-2001240625-\$ or JP-2001188346-\$ or JP-2001142213-\$).did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/27 13:13
10	47	(alicyclic adamantane cyclohexane norbornane) adj lactone	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/27 13:14
11	8	(SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA AOA-T AOAI-TOSHIAKI AOA-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F) and ((alicyclic adamantane cyclohexane norbornane) adj lactone)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/27 13:13
12	39	((alicyclic adamantane cyclohexane norbornane) adj lactone) not ((SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA AOA-T AOAI-TOSHIAKI AOA-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F) and ((alicyclic adamantane cyclohexane norbornane) adj lactone))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/27 13:21
13	2	("6306554").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/27 13:21

-	1863077	resin resist photoresist	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 13:55
-	8221	((resin resist photoresist) and (acid near generat\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/10 12:17
-	1522	"3" and (positive near composition)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/10 12:24
-	203	((resin resist photoresist) and (acid near generat\$4)) and (positive near composition)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/10 12:24
-	3892	((resin resist photoresist) and (acid near generat\$4)) and (positive )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/10 12:43
-	0	("us-20010039080-A1.did.").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/10 12:32
-	2	("20010039080").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/10 12:32
-	0	20010039080.URPN.	USPAT	2002/10/10 12:43
-	801	((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/10 14:19
-	288	((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 14:45
-	721	SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/15 14:57
-	30	((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 18:35
-	258	((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) not (((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/10 16:06
-	79	((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) not (((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F))) and (lactone)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/15 14:57

-	289	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/15 15:00
-	723	SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHI AKI AOA I-TOSHI AKI-C-O-FUGI-PHOTO-F AOA I-TOSHI AKI-C-O-FUJI-PHOTO-F	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/15 15:01
-	259	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4) ) not (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHI AKI AOA I-TOSHI AKI-C-O-FUGI-PHOTO-F AOA I-TOSHI AKI-C-O-FUJI-PHOTO-F )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 18:38
-	79	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) not ((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHI AKI AOA I-TOSHI AKI-C-O-FUGI-PHOTO-F AOA I-TOSHI AKI-C-O-FUJI-PHOTO-F))) and (lactone)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 18:38
-	180	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4) ) not (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHI AKI AOA I-TOSHI AKI-C-O-FUGI-PHOTO-F AOA I-TOSHI AKI-C-O-FUJI-PHOTO-F ) ) not ((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) not ((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHI AKI AOA I-TOSHI AKI-C-O-FUGI-PHOTO-F AOA I-TOSHI AKI-C-O-FUJI-PHOTO-F))) and (lactone) )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/15 16:11
-	2	US-20010039080-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/15 19:07
-	549	(resist photoresist) and (norborn\$5) and (\$5acid near generat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/16 11:41
-	96	((resist photoresist) and (norborn\$5) and (\$5acid near generat\$3)) and( (norborn\$5) same (conventional enhanc\$5 improv\$5 benef\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/16 11:44
-	71	((resist photoresist) and (norborn\$5) and (\$5acid near generat\$3)) and( (norborn\$5) same (conventional enhanc\$5 improv\$5 benef\$3))) and positive	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 14:20
-	325	norbornene same (acrylate methacrylate) same (maleic adj anhydride)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/16 11:54
-	7	"6284429"	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/10/16 14:53

-	18	(((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) ) and (lactone)) and (((US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$).did. or (US-20010041303-\$ or US-20020009666-\$ or US-20020132181-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20020004569-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$).did.) ((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F) )) ) not ((US-6448420-\$ or US-6280898-\$ or US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$).did. or (US-20020009666-\$ or US-20010041303-\$ or US-20020132181-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20020004569-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$).did. or (JP-2001142213-\$ or JP-2001188346-\$ or JP-2001240625-\$).did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 19:02
-	341	(resist photoresist) and (lactone) and ((maleic adj anhydride) (maleimide)) and (norbornene norbornyl)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 14:41
-	17155	(acid photoacid) near generat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 14:41
-	87099	positive near5 (composition working image pattern type)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 14:44
-	4069	((acid photoacid) near generat\$4) and (positive near5 (composition working image pattern type))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 14:45
-	235	(((acid photoacid) near generat\$4) and (positive near5 (composition working image pattern type))) and ((resist photoresist) and (lactone) and ((maleic adj anhydride) (maleimide)) and (norbornene norbornyl))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 14:45

-	930	((fluorine silicon) near5 surfactant) same (conventional improvement enhance enhancement improve benefit beneficial )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 16:59
-	0	((((fluorine silicon) near5 surfactant) same (conventional improvement enhance enhancement improve benefit beneficial )) and (positive near5 (composition working image pattern type)) and ((acid photoacid) near generat\$4) and ((resist photoresist) and (lactone) and ((maleic adj anhydride) (maleimide)) and (norbornene norbornyl))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:00
-	49	((((fluorine silicon) near5 surfactant) same (conventional improvement enhance enhancement improve benefit beneficial )) and (positive near5 (composition working image pattern type)) and ((acid photoacid) near generat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:10
-	24	((((fluorine silicon) near5 surfactant) same (conventional improvement enhance enhancement improve benefit beneficial )) and (positive near5 (composition working image pattern type)) and ((acid photoacid) near generat\$4)	USPAT	2003/10/24 17:06
-	2	("4822713").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:06
-	138	(fluorine-type silicon-type) near5 surfactant	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:10
-	4	((fluorine-type silicon-type) near5 surfactant) and (positive near5 (composition working image pattern type)) and ((acid photoacid) near generat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:11
-	13952	((((fluorine-type silicon-type) near5 surfactant) same (conventional improvement enhance enhancement improve benefit beneficial )) and (positive near5 (composition working image pattern type)) and ((acid photoacid) near generat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:11
-	0	((((fluorine-type silicon-type) near5 surfactant) same (conventional improvement enhance enhancement improve benefit beneficial )) and (positive near5 (composition working image pattern type)) and ((acid photoacid) near generat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:12
-	1	((((fluorine-type silicon-type) near5 surfactant) same (conventional improvement enhance enhancement improve benefit beneficial )) and (positive near5 (composition working image pattern type))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:12
-	18	((fluorine-type silicon-type) near5 surfactant) same (conventional improvement enhance enhancement improve benefit beneficial )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/10/24 17:12
-	6	((("6579659") or ("5478869") or ("6280898")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/22 17:44
-	0	20010044070.URPN.	USPAT	2004/05/22 19:11
-	0	20020009666.URPN.	USPAT	2004/05/22 19:14
-	55	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 18:47

-	186	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) not (((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F))) and (lactone)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 19:02
-	55	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 19:01
-	9	("4018767"   "4166915"   "4188219"   "5185143"   "5541344"   "5811462"   "5910392"   "6008306"   "6057083").PN.	USPAT	2004/05/26 18:55
-	13	6280898.URPN.	USPAT	2004/05/26 18:57
-	55	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 19:02
-	186	(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) not (((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F))) and (lactone)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 19:24

	20	<p>(((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) ) and (lactone)) and ((US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$).did. or (US-20010041303-\$ or US-20020009666-\$ or US-20020132181-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20020004569-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$).did.) (((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F) )) ) not ((US-6448420-\$ or US-6280898-\$ or US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$).did. or (US-20020009666-\$ or US-20010041303-\$ or US-20020132181-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20020004569-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$).did. or (JP-2001142213-\$ or JP-2001188346-\$ or JP-2001240625-\$).did.)</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 19:02
	38	<p>(US-6251560-\$ or US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6248920-\$ or US-6207342-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$ or US-6548220-\$ or US-5695906-\$ or US-6461788-\$).did. or (US-20020009666-\$ or US-20020132181-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$ or US-20010044070-\$ or US-20030059715-\$).did. or (JP-2001240625-\$ or JP-2001188346-\$ or JP-2001142213-\$).did.</p>	USPAT; US-PGPUB; JPO	2004/05/26 19:02

-	20	(((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) ) and (lactone)) and (((US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$).did. or (US-20010041303-\$ or US-20020009666-\$ or US-20020132181-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20020004569-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$).did.) (((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOAI AOAI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-F) )) ) not ((US-6448420-\$ or US-6280898-\$ or US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$).did. or (US-20020009666-\$ or US-20010041303-\$ or US-20020132181-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20020004569-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$).did. or (JP-2001142213-\$ or JP-2001188346-\$ or JP-2001240625-\$).did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 19:05
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-	167	((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) not ((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHIAKI AOA I-TOSHIAKI-C-O-FUGI-PHOTO-F AOA I-TOSHIAKI-C-O-FUJI-PHOTO-F))) and (lactone) ) not (((("4018767"   "4166915"   "4188219"   "5185143"   "5541344"   "5811462"   "5910392"   "6008306"   "6057083").PN.) 6280898.URPN. ((US-6251560-\$ or US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6248920-\$ or US-6207342-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$ or US-6548220-\$ or US-5695906-\$ or US-6461788-\$).did. or (US-20020009666-\$ or US-20020132181-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$ or US-20010044070-\$ or US-20030059715-\$).did. or (JP-2001240625-\$ or JP-2001188346-\$ or JP-2001142213-\$).did.) (((((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHIAKI AOA I-TOSHIAKI-C-O-FUGI-PHOTO-F AOA I-TOSHIAKI-C-O-FUJI-PHOTO-F) ) (((((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) ) and (lactone)) and (((US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$).did. or (US-20010041303-\$ or US-20020009666-\$ or US-20020132181-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20020004569-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$).did.) (((((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHIAKI AOA I-TOSHIAKI-C-O-FUGI-PHOTO-F AOA I-TOSHIAKI-C-O-FUJI-PHOTO-F) ) ) ) not ((US-6448420-\$ or US-6280898-\$ or US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$).did. or (US-20020009666-\$ or US-20010041303-\$ or US-20020009668-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/26 19:24
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-	167	<p>(((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) not ((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHIAKI AOA I-TOSHIAKI-C-O-FUGI-PHOTO-F AOA I-TOSHIAKI-C-O-FUJI-PHOTO-F))) and (lactone) ) not (((("4018767"   "4166915"   "4188219"   "5185143"   "5541344"   "5811462"   "5910392"   "6008306"   "6057083").PN.) 6280898.URPN. ((US-6251560-\$ or US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6248920-\$ or US-6207342-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$ or US-6548220-\$ or US-5695906-\$ or US-6461788-\$).did. or (US-20020009666-\$ or US-20020132181-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$ or US-20010044070-\$ or US-20030059715-\$).did. or (JP-2001240625-\$ or JP-2001188346-\$ or JP-2001142213-\$).did.) ((((((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHIAKI AOA I-TOSHIAKI-C-O-FUGI-PHOTO-F AOA I-TOSHIAKI-C-O-FUJI-PHOTO-F) ) ((((((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) ) and (lactone)) and (((US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$ or US-6448420-\$ or US-6280898-\$).did. or (US-20010041303-\$ or US-20020009666-\$ or US-20020132181-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or US-20020058201-\$ or US-20020051936-\$ or US-20020051935-\$ or US-20020048724-\$ or US-20020009668-\$ or US-20020009667-\$ or US-20020004569-\$ or US-20010038969-\$ or US-20010033989-\$ or US-20010018162-\$ or US-20010010890-\$ or US-20010003640-\$).did.) ((((((((((resin resist photoresist) and (acid near generat\$4)) and (positive )) and (norborn\$5 alicyclic)) and (alkaline adj develop\$4)) and (SATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO AOA I AOA I-T AOA I-TOSHIAKI AOA I-TOSHIAKI-C-O-FUGI-PHOTO-F AOA I-TOSHIAKI-C-O-FUJI-PHOTO-F) ) ) not ((US-6448420-\$ or US-6280898-\$ or US-6403280-\$ or US-6388101-\$ or US-6329125-\$ or US-6303266-\$ or US-6284429-\$ or US-6270941-\$ or US-6251560-\$ or US-6248920-\$ or US-6207342-\$ or US-6200725-\$ or US-6077644-\$ or US-6013416-\$ or US-5968713-\$ or US-5929271-\$ or US-5910392-\$).did. or (US-20020009666-\$ or US-20010041303-\$ or US-20020098441-\$ or US-20020081523-\$ or US-20020061465-\$ or</p>	<p>USPAT; US-PGPUB; EPO; JPO; DERWENT</p>	2004/05/27 13:07
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